

**TRANSMITTAL LETTER TO THE UNITED STATES
DESIGNATED/ELECTED OFFICE (DO/EO/US)
CONCERNING A FILING UNDER 35 U.S.C. 371**

Attorney Docket No. 01184

U.S. Application No. (if known,
see 37 CFR 1.57)

09/926289

INTERNATIONAL APPLICATION NO.
PCT/FR00/01112

INTERNATIONAL FILING DATE
April 26, 2000

PRIORITY DATE CLAIMED
April 27, 1999

TITLE OF INVENTION

IMPROVED METHOD AND DEVICE FOR DEGASSING AND SEPARATION OF INCLUSIONS IN A LIQUID METAL BATH BY INJECTION OF GAS BUBBLES

APPLICANT(S) FOR DO/EO/US

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Applicant herewith submits to the United States Designated Office (DO/EO/US) the following items and other information:

1. ☒ This is a **FIRST** submission of items concerning a filing under 35 U.S.C. 371.
2. ☐ This is a **SECOND** or **SUBSEQUENT** submission of items concerning a filing under 35 U.S.C. 371.
3. ☐ This is an express request to begin national examination procedures (35 U.S.C. 371(f)) at any time rather than delay examination until the expiration of the applicable time limit set in 35 U.S.C. 371(b) and PCT Articles 22 and 39(1).
4. ☒ A proper Demand for International Preliminary Examination was made by the 19th month from the earliest claimed priority date.
5. ☒ A copy of the International Application as filed (35 U.S.C. 371(c)(2))
 - a. ☐ is transmitted herewith (required only if not transmitted by the International Bureau).
 - b. ☒ has been transmitted by the International Bureau.
 - c. ☐ is not required, as the application was filed in the United States Receiving Office (RO/US).
6. ☒ A translation of the International Application into English (35 U.S.C. 371(c)(2)).
7. ☐ Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. 371(c)(3)).
 - a. ☐ are transmitted herewith (only if not required by the International Bureau).
 - b. ☐ have been transmitted by the International Bureau.
 - c. ☐ have not been made; however, the time limit for making such amendments has NOT expired.
 - d. ☐ have not been made and will not be made.
8. ☐ A translation of the amendments to the claims under PCT Article 19 (35 U.S.C. 371(c)(3)).
9. ☐ An oath or declaration of the inventor(s) (35 U.S.C. 371(c)(4)).
10. ☐ A translation of the annexes to the International Preliminary Examination Report under PCT Article 36 (35 U.S.C. 371(c)(5)).

Items 11 to 16 below concern document(s) or information included:

11. ☒ An Information Disclosure Statement under 37 CFR 1.97 and 1.98.
12. ☐ As assignment document for recording. A separate cover sheet in compliance with 37 CFR 3.28 and 3.31 is included.
13. ☒ A **FIRST** preliminary amendment.
☐ A **SECOND** or **SUBSEQUENT** preliminary amendment.
14. ☐ A substitute specification.
15. ☐ A change of power of attorney and/or address letter.
16. ☐ Other items or information:
Application Data Sheet



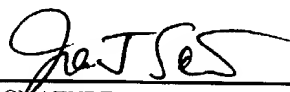
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PATENT TRADEMARK OFFICE

17. <input checked="" type="checkbox"/> The following fees are submitted:				CALCULATIONS PTO USE ONLY	
BASIC NATIONAL FEE (37 CFR 1.492 (a)(1)-(5):					
Neither international preliminary examination fee (37 CFR 1.482)					
Nor international search fee (37 CFR 1.445(a)(2)) paid to USPTO					
And International Search Report not prepared by EPO or JPO..... \$1,040.00					
International preliminary examination fee (37 CFR 1.482) not paid to USPTO but International Search Report prepared by EPO or JPO.....\$890.00					
International preliminary examination fee (37 CFR 1.482) not paid to USPTO but International search fee (37 CFR 1.445(a)(2)) paid to USPTO..... \$740.00					
International preliminary examination fee paid to USPTO (37 CFR 1.482) But all claims did not satisfy provisions of PCT Article 33(1)-(4).....\$710.00					
International preliminary examination fee paid to USPTO (37 CFR 1.482) And all claims satisfied provisions of PCT Article 33(1)-(4)..... \$100.00					
ENTER APPROPRIATE BASIC FEE AMOUNT =				\$890.00	
Surcharge of \$130.00 for furnishing oath or declaration later than <input type="checkbox"/> 20 <input checked="" type="checkbox"/> 30 months from the earliest claimed priority date (37 CFR 1.492(e)).				\$130.00	
CLAIMS	NUMBER FILED	NUMBER EXTRA	RATE		
Total Claims	16 -20=		X \$18.00	\$	
Independent Claims	2 -3=		X \$84.00	\$	
MULTIPLE DEPENDENT CLAIM(S) (if applicable)				\$	
TOTAL OF ABOVE CALCULATIONS =				\$1020.00	
Reduction of 1/2 for filing by small entity, if applicable. A Small Entity Statement must also be filed (Note 37 CFR 1.9, 1.27, 1.28).				\$	
SUBTOTAL =				\$1020.00	
Processing fee of \$130.00 for furnishing English translation later than <input type="checkbox"/> 20 <input type="checkbox"/> 30 months from the earliest claimed priority date (37 CFR 1.492(f)).				\$	
TOTAL NATIONAL FEE =				\$1020.00	
Fee for recording the enclosed assignment (37 CFR 1.21(h)). The assignment must be accompanied by an appropriate cover sheet (37 CFR 3.28, 3.31).				\$	
TOTAL FEES ENCLOSED =				\$1020.00	
				Amount to be refunded:	\$
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- a. ☐ A check in the amount of \$ to cover the above fees is enclosed.
- b. ☐ Please charge my Deposit Account No. 04-0753 in the amount of \$ to cover the above fees. A duplicate copy of this sheet is enclosed.
- c. ☐ The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment to Deposit Account No. 04-0753. A duplicate copy of this sheet is enclosed.
- d. ☒ A payment of \$ 1020.00 is made by credit card. A Credit Card Payment Form (PTO-2038) is attached hereto. The Commissioner is hereby authorized to charge payment of any additional filing fees required under 37 CFR 1.16 or any patent application processing fees under 37 CFR 1.17, or credit any over payment to the credit card account shown on the attached Credit Card Payment Form. Refund of all amounts overpaid, including those of twenty-five dollars or less, is specifically requested. Any fees not accepted by the credit card shown on Form PTO-2038 may be charged to Deposit Account No. 04-0753.

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REGISTRATION NUMBER

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09/926289
410 Rec'd PCT/PTO 09 OCT 2001

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APPLICATION INFORMATION

Title Line One:: IMPROVED METHOD AND DEVICE FOR DEGASSING
Title Line Two:: AND SEPARATION OF INCLUSIONS IN A LIQUI
Title Line Three:: D METAL BATH BY INJECTION OF GAS BUBBLES
Total Drawing Sheets:: 1
Formal Drawings?:: Yes
Application Type:: Utility

Docket Number:: 01184
Secrecy Order i parent Appl.?: No

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REPRESENTATIVE INFORMATION

5
Registration Number One:: 19920
Registration Number Two:: 24018
Registration Number Three:: 28666
Registration Number Four:: 37750
Registration Number Five:: 40250

CONTINUITY INFORMATION

This application is a:: 371 OF
> Application One:: PCT/FR00/01112
Filing Date:: 04-26-2000
Patent Number:: WO00/65109

PRIOR FOREIGN APPLICATIONS

Foreign Application One:: 99/05484
Filing Date:: 04-27-1999
Country:: France
Priority Claimed:: Yes

Source:: PrintEFS Version 1.0.1

Dkt. 01184

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

PIERRE LE BRUN et al

PCT

Serial No.: none assigned
(PCT/FR00/01112)

Filed: Concurrently Herewith

For: IMPROVED METHOD AND DEVICE FOR DEGASSING AND
SEPARATION OF INCLUSIONS IN A LIQUID METAL
BATH BY INJECTION OF GAS BUBBLES

PRELIMINARY AMENDMENT AND INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner of Patents and Trademarks
Washington, D.C. 20231

Sir:

Before calculation of the filing fee, please amend
the above-identified application as follows:

IN THE SPECIFICATION:

Please enter into the application the amendments set
forth hereinbelow and in the attached Appendix:

Page 1, above line 1: Field of the invention;

line 7: State of the art

Page 3, line 3: Summary of the invention

--Brief description of the drawings

between lines 12 and 13, insert:

--Description of the preferred embodiments--

Please enter into the application the amended claims as set forth hereinbelow and in the attached Appendix:

Page 12, above line 1: WHAT IS CLAIMED IS:

4. (Amended) Device according to claim 2,
characterised in that the orifices are located at the top of
tapered protuberances.

5. (Amended) Device according to claim 1,
characterised in that the spreading ratio is obtained
by mechanically or geometrically limiting the said contact
area.

7. (Amended) Device according to claim 5,
characterised in that when the material used for the static
part (21) is non wettable, each protuberance (32) comprises
only one gas emission orifice (22).

15. (Amended) Process for the treatment of a liquid metal (3, 23) by injection of a gas, making use of the static gas injection device according to claim 1.

16. (Amended) Treatment process according to claim 14, characterised in that the bubble size (11, 31) is measured using a method consisting of irradiating the liquid metal bath (3, 23) into which the bubbles are emitted using X-rays, displaying the said bubbles after the image has been retrieved by a camera, and measuring them after calibration of the acquisition system.

The specification has been amended to add proper subject matter headings and a section entitled Brief Description of the Drawings.

The claims have been amended to delete the multiple dependencies.

Attached hereto is the Search Report of the corresponding PCT application, with copies of the references cited therein which are listed on the attached Form PTO-1449.

Respectfully submitted,

Joe J. Schult
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APPENDIX

IN THE SPECIFICATION:

Page 1, above line 1: [Technical Domain] Field of the invention;

line 7, [Sate] State of the art

Page 3, line 3, [Description] Summary of the invention

IN THE CLAIMS:

Page 12, above line 1: [CLAIMS] WHAT IS CLAIMED IS:

4. (Amended) Device according to claim 2 [or 3], characterised in that the orifices are located at the top of tapered protuberances.

5. (Amended) Device according to [anyone of claims 1 to 4] claim 1, characterised in that the spreading ratio is obtained by mechanically or geometrically limiting the said contact area.

7. (Amended) Device according to claim 5 [or 6], characterised in that when the material used for the static part (21) is non wettable, each protuberance (32) comprises only one gas emission orifice (22).

8. (Amended) Device according to claim 6 [or 7], characterised in that at least one of the protuberances (32) is removable.

9. (Amended) Device according to [anyone of claims 1 to 8] claim 1, characterised in that it comprises means such that the gas pressure at the outlet orifice is approximately constant, regardless of the gas flow.

11. (Amended) Device according to [anyone of claims 1 to 10] claim 1, characterised in that a shearing energy is added to the liquid metal (3, 23) preferably by means of ultra sounds or a rotary stirrer.

12. (Amended) Device according to [anyone of claims 1 to 11] claim 1, characterised in that the orifices (2, 22) are separated from each other by a distance such that the bubbles do not come into contact while they are being formed.

13. (Amended) Device according to [anyone of claims 1 to 12] claim 1, characterised in that the static injection part (1, 21) is made of one or several elements assembled together.

15. (Amended) Process for the treatment of a liquid metal (3, 23) by injection of a gas, making use of the static gas injection device according to [anyone of claims 1 to 13] claim 1.

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IMPROVED PROCESS AND METHOD FOR DEGASSING AND
SEPARATION OF INCLUSIONS IN A LIQUID METAL BATH BY
INJECTION OF GAS BUBBLES

Technical domain

The invention relates to a process and a device for improving the degassing treatment and separation of inclusions in a liquid metal bath, and particularly aluminium, magnesium or their alloys, by injection and
5 dispersion of a gas in the said liquid metal.

State of the art

It is known that before semi-finished metallurgical products such as aluminium, magnesium and
10 their alloys can be obtained by casting, the unfinished liquid metal has to be treated to eliminate dissolved gases (particularly hydrogen), dissolved impurities (particularly alkalis) and solid or liquid inclusions that would reduce the quality of the cast parts.

15 This treatment is usually done by insufflation of an appropriate gas, for example an inert gas insoluble in a liquid metal such as Ar that can contain a few percent of a reactive chlorine type gas.

If this treatment is to be efficient, the bubble
20 diameter must be as small as possible to give a large contact area between the gas and the metal.

For example, patent application FR 2 727 432 in the name of the applicant discloses the insufflation of gas through a porous material inert to the liquid
25 metal, usually based on graphite or alumina.

But this approach cannot be used to control the flow and size of the emitted gas bubbles. When the pores are too large, firstly the bubbles are too large,

they are not efficient, the gas being insufficiently dispersed in the liquid metal, and the result is unwanted surface movements, and furthermore it is essential that the gas flow through the pores is not
5 stopped to prevent the liquid metal from penetrating into them, particularly during rest periods between two pours. On the other hand, when the pores are too small, the bubbles spread and remain large; it is also difficult to introduce a high gas flow inside the
10 liquid metal.

Thus, the device in the application mentioned above tends to get around this difficulty of controlling the bubble diameter and obtaining small diameter bubbles by means of a particular layout of gas
15 emitting devices.

Similarly, patent US 4714494 describes a process for reducing the diameter of bubbles emitted through a porous medium. This process consists of treating the liquid metal in a long chute, the bottom of which is
20 made of a porous material through which the gas is inlet and in which the said liquid metal circulates at speed of at least 0.1 cm/sec, and preferably at least 2.5 cm/sec. Although the bubble diameter can be reduced with this process, it is still large.
25 Furthermore, it is not easy to control the liquid metal at high speed, there may be safety risks and a high speed may not be compatible with a good quality of liquid metal, considering the swirling that may take place within its mass.

30 Thus, there are several known processes that make use of porous diffusers to obtain bubbles of the order of 30 to 50 mm diameter at best, even if the pores are very fine, for example less than 1 mm, or liquid metal

circulation speeds of the order of magnitude of those described in US patent 4714494.

American patent US 4 290 590 describes a gas bubble injection device comprising a plate of inert material and a series of protuberances provided with orifices in their upper part and supplied by a gas source in their lower part. The orifice of the protuberances should be as small as possible, which has the disadvantage of necessitating a large number of protuberances to obtain a sufficient gas flow.

The applicant has continued making efforts to control and reduce the diameter of bubbles emitted by a static gas insufflation device and thus make it more efficient.

15

Description of the invention

The invention is a device for the injection of gas bubbles into a liquid metal contained in a treatment volume, the said device comprising at least one static injection part (also called emitter) made of a substantially inert material, the said static part comprising a plurality of orifices, the said device being characterised in that the material and/or layout of the orifices are such that the ratio of the diameter of the contact area between each emitted bubble and the said material at the exit from the orifice, to the outlet diameter of the orifice, or the spreading ratio, is less than 5, preferably less than 3, or more preferably less than 1.5.

30 The treatment volume or container is usually a tank with one or several compartments, a liquid metal circulation chute, a furnace, etc.

The orifice diameter is equal to not more than the diameter of the bubble to be obtained, and the smaller the bubble diameter to be obtained the smaller the required spreading ratio. The device according to the invention is particularly useful when it is required to obtain bubbles with a diameter not larger than 20 mm and advantageously not more than 10 mm, even when the liquid is calm or is circulating at low speed. The bubble diameter can be even smaller when the liquid metal is circulating at a higher speed.

The required spreading ratio may be obtained using a material that can be wetted by the liquid metal, in other words if the wetting angle is less than 90° , and/or by geometrically limiting the spreading area available around the orifice; the latter solution makes it possible to use diffusers made of a material that cannot be wetted by the liquid metal.

FIGURE 1 (a and b) illustrates the difference in behaviour between a wettable and non-wettable material within the context of the invention.

(1) shows the static emitter body, (2) shows the gas inlet orifice at which a bubble (9) is formed on the surface of the emitter, the said orifice (2) being supplied with gas through a small channel formed in the emitter.

When the material is wettable by the liquid metal (case in FIGURE 1a), the wetting angle (10) defined by the tangent to the bubble (9) at its contact point with the emitter and by the emitter is less than 90° . It can be seen that if the metal thoroughly wets the emitter material, the spreading of the bubble (9) is reduced and the diameter is limited. This mechanism, that occurs even if the surface surrounding the orifice

(2) forms an angle other than 90° with the inside surface of the orifice, is a means of allowing the gas to escape through protuberances made of a material that can be wetted by the metal, for example in the shape of drilled cones in which the orifice passes through the axis of symmetry, in other words the orifices may be located at the top of tapered protuberances. However, the use of a static emitter without a protuberance does have the advantage that it simplifies production of the device, and reduces the risks of geometry changes due to erosion and dirt accumulation on the device. The protuberances may possibly be formed from separate parts that are fixed together by mechanical means such as fasteners, which makes it easy to change them if damage occurs.

When the material cannot be wetted by the liquid metal (case in FIGURE 1b), the wetting angle (θ) is greater than 90° . It can be seen that the bubble can spread because the metal cannot easily wet the emitter; in this case it is important to mechanically or geometrically limit the spreading area of the said bubble, as will be seen later, to ensure that its diameter is small.

The said contact area means the maximum contact surface A between each emitted bubble and the said material at the exit from the orifice. When a bubble develops, the contact area usually increases very quickly towards its maximum value. The maximum contact area can be measured using any means for displaying the formation of gas bubbles such as X-rays.

In the case of aluminium or magnesium and their liquid alloys, the wettable material of the diffuser may be chosen among some refractory metals that are

substantially inert to the said liquid metals, such as Mo, W, V, Ti, Cr, Fe, steels, etc., or their alloys, or among ceramics such as TiB_2 , nitrides (AlN , BN), carbides (Al_4C_3 , TiC_{1-x}), etc. In this respect, it can
5 be noted that normally the graphite or aluminium is not wettable by these liquid metals. ZrO_2 and SiC are also materials that cannot be wetted by aluminium and its alloys. The wetting behaviour of the material also depends on the roughness and the oxidation condition of
10 its surface. The material is preferably wetting since in this case it is easier to obtain a low spreading ratio.

In order to physically limit the spreading ratio, the diffuser may comprise several small protuberances,
15 the area at the top of these protuberances corresponding to the said contact area or spreading area of the bubble and comprises at least one gas emission orifice. With this type of diffuser, it can be seen that it is possible to use materials that are
20 not wettable by the liquid metal; in this case, it is preferable to use a single orifice on the top of the protuberance. The height of these protuberances is preferably equal to at least said diameter, and their shape is preferably in the form of a straight or
25 inclined cylindrical or tapered projection. The protuberances (32) or part of these protuberances may be removable, in other words they may form inserts so that they can be replaced if they are worn or damaged. The removable protuberances (or projections) may be
30 fixed to the body of the static part (21) by fasteners or by any means that enable easy replacement of the protuberances.

The diffuser may be in the form of a single part or an assembly of elementary parts, usually thin parts in which small conduits have been drilled. The top end of these conduits forms the injection orifice located on the surface of the said diffuser in contact with the liquid metal, and their lower end forms the orifice into which the supply gas flow to be injected into the liquid metal is inlet. The distance between two adjacent injection orifices is typically slightly greater than the distance corresponding to the diameter of the spreading surface and is such that the bubbles do not touch each other while they are being formed. The conduits may correspond to a system of pores or may communicate through a network of feed conduits formed in the mass.

It is important that the gas pressure at the outlet orifice, at the interface between the metal and the surface of the emitter, is approximately constant regardless of the gas flow, particularly during formation and detachment of the bubble, in order to have better control over the bubble diameter. In this respect, it is advantageous to design the device such that the bubble volume located between the gas outlet orifice and the closest gas supply adjustment device (valve, flow meter, etc.) is as small as possible, and/or to use an appropriate mass flow meter, and/or to introduce a local pressure head loss just on the upstream side of the outlet orifice, for example using a porous material.

In order to further reduce the bubble diameter, it could be advantageous to inject a shearing energy into the liquid metal, for example by means of ultrasounds

The injection device according to the invention is advantageously used for the treatment of volumes of aluminium, magnesium, or their liquid alloys. For example, it may be installed in the bottom of liquid metal treatment tanks or compartments of these tanks, or in the bottom of circulation chutes for the said liquid metal.

The invention also relates to any process for the treatment of a liquid metal using gas bubbles with a diameter of not more than 20 mm, or preferably not more than 10 mm generated by a static diffuser, the products obtained by this process and the corresponding device. Tests carried out with this device according to the invention have shown that it is possible to achieve degassing efficiencies of up to 50% with bubbles with a diameter of the order of 5 mm, compared with previous efficiencies of less than 5% with bubbles with a diameter of the order of 40 mm. The invention also relates to any process for the treatment of liquid metals by the injection of gas using the static injection device according to this invention. For the embodiment of the treatment process, the material and/or the layout of the orifices in the static part (1, 21) may be chosen as a function of the nature of

the liquid metal, and possibly as a function of the gas composition and/or the temperature of the liquid metal.

The process may include measurement of the size of the bubbles under treatment, for example using X-rays,
5 sound or ultrasound probes.

The drawings and the examples given below illustrate the invention.

FIGURE 2 shows a partial sectional view of an example diffuser used to obtain the spreading ratio
10 according to the invention and FIGURE 3 shows a view of another diffuser according to the invention under the same conditions.

FIGURE 2 shows the static diffuser at (1) in the form of a piece of material that is wettable by the
15 liquid metal, usually installed in the bottom of a liquid aluminium treatment volume (not shown) comprising several injection orifices (2) in contact with the liquid metal (3). A treatment gas feed orifice (5) emerges on the lower face (4) of the part
20 (1), the treatment gas being transported to the injection orifice (2) through the buffer volume (8). The diffuser rests on supports not shown and several diffusers may be installed in the same treatment volume as described in application FR 2727432 mentioned above.

25 With a 0.2 cm thick part (1) made of Ti (wettable by aluminium) with 1.0 mm diameter orifices (2) at a spacing of 15 mm from each other, the bubble (9) being formed has a wetting angle (10) equal to about 70° and a spreading ratio of about 1. The diameter of the
30 bubbles formed (11) was measured by an X-ray method consisting essentially of irradiating the liquid metal bath in which the gas bubbles are emitted, and displaying the said bubbles as light images on a dark

background after retrieving the image by a camera; the diameter of the bubbles is then measured after calibration of the acquisition system.

The diameter is 5 mm while the metal is calm
5 without the addition of any external shearing energy.

FIGURE 3 shows details of another method of limiting the spreading ratio. The static diffuser (21) placed in the bottom of a liquid metal treatment volume (23) is in the form of a part comprising injection
10 orifices (22) through which the treatment gas is diffused into the liquid metal (23). These orifices are located at the top of the protuberances (32), and the top diameter is used with the orifice diameter to calculate the said spreading ratio. The injection
15 orifices (22) are connected to the feed orifice (25) located on the lower face (24) of the part (21) through the buffer volume (28) that is as small as possible. As before, the constant pressure feed device (26) is on the upstream side of the said lower face (24).

20 With a graphite part (not wettable by aluminium) with orifices (22) with a diameter of 2 mm located at the top of small 10 mm diameter cylinders, thus with a spreading ratio of 5 with a height of 10 mm above the surface of the rest of the diffuser and with a spacing
25 of 40 mm from each other, it is possible to obtain bubbles (31) with a diameter of about 10 mm. It can be seen that the bubble being formed (29) does not project beyond the periphery of the individualised non-wettable cylindrical projection (32) on which it is formed.

30 The constant pressure of gas supply device (6, 26), for example comprising graphite felt introducing a pressure loss between the supply gas flow (7, 27) and the buffer volume (8, 28) that is as small as possible,

is located on the upstream side of the lower face (4, 24) and typically at the orifice (5, 25).

Tests carried out with the device according to the invention have showed that the choice of material and the layout of the orifices alone is sufficient to efficiently control the size of the bubbles, even if this choice can be made as a function of the nature of the metal to be treated and/or, in some cases, as a function of the gas composition and/or the temperature of the liquid metal.

CLAIMS

1. Device for the injection of gas bubbles into a liquid metal (3, 23) contained in a treatment volume, preferably a treatment tank, a liquid metal circulation chute or a furnace, the said device comprising at least
5 one static injection part (1, 21) made of an inert material, the said static part (1, 21) comprising a plurality of orifices (2, 22), the said device being characterised in that the material and/or layout of the orifices are such that the ratio of the diameter of the
10 contact area between each emitted bubble and the said material at the exit from the orifice (2, 22), to the diameter of the orifice, or the spreading ratio, is less than 5, preferably less than 3, or more preferably less than 1.5.

15 2. Device according to claim 1, characterised in that the spreading ratio is obtained using a static part (1, 21) made by a material that is wettable by the liquid metal (3, 23).

20 3. Device according to claim 2, characterised in that when the liquid metal (3, 23) is aluminium, magnesium or their alloys, the wettable material is chosen among refractory metals such as W, Mo, Ti, V, Cr, Fe or steels or their alloys, or among refractory ceramics such as TiB_2 , nitrides (AlN , BN) or carbides
25 (Al_4C_3 , TiC_{1-x})

4. Device according to claim 2 or 3, characterised in that the orifices are located at the top of tapered protuberances.

30 5. Device according to any one of claims 1 to 4, characterised in that the spreading ratio is obtained

by mechanically or geometrically limiting the said contact area.

6. Device according to claim 5, characterised in that, so as to geometrically limit the contact area,
5 the orifices (2, 22) are located at the top of protuberances (32) located on the static part (1, 21).

7. Device according to claim 5 or 6, characterised in that when the material used for the static part (21) is non wettable, each protuberance
10 (32) comprises only one gas emission orifice (22).

8. Device according to claim 6 or 7, characterised in that at least one of the protuberances (32) is removable.

9. Device according to any one of claims 1 to 8,
15 characterised in that it comprises means such that the gas pressure at the outlet orifice is approximately constant, regardless of the gas flow.

10. Device according to claim 9, characterised in that the said means comprise the smallest possible
20 buffer volume between the gas outlet orifice and the closest gas supply adjustment device and/or an appropriate mass flow meter and/or a porous means introducing a local pressure head loss just on the upstream side of the gas outlet orifice.

25 11. Device according to any one of claims 1 to 10, characterised in that a shearing energy is added to the liquid metal (3, 23) preferably by means of ultrasounds or a rotary stirrer.

12. Device according to any one of claims 1 to 11,
30 characterised in that the orifices (2, 22) are separated from each other by a distance such that the bubbles do not come into contact while they are being formed.

13. Device according to any one of claims 1 to 12, characterised in that the static injection part (1, 21) is made of one or several elements assembled together.

5 14. Process for treatment of a liquid metal (3, 23) by injection of a gas using a static gas injection device (1, 21) according to any one of claims 1 to 13, characterised in that the diameter of the bubbles (11, 31) of the treatment gas introduced into the liquid metal (3, 23) is smaller than 20 mm and preferably
10 smaller than 10 mm, with the liquid metal (3, 23) being at rest.

15 15. Process for the treatment of a liquid metal (3, 23) by injection of a gas, making use of the static gas injection device according to any one of claims 1 to 13.

16. Treatment process according to either of claims 14 and 15, characterised in that the bubble size (11, 31) is measured using a method consisting of irradiating the liquid metal bath (3, 23) into which
20 the bubbles are emitted using X-rays, displaying the said bubbles after the image has been retrieved by a camera, and measuring them after calibration of the acquisition system.

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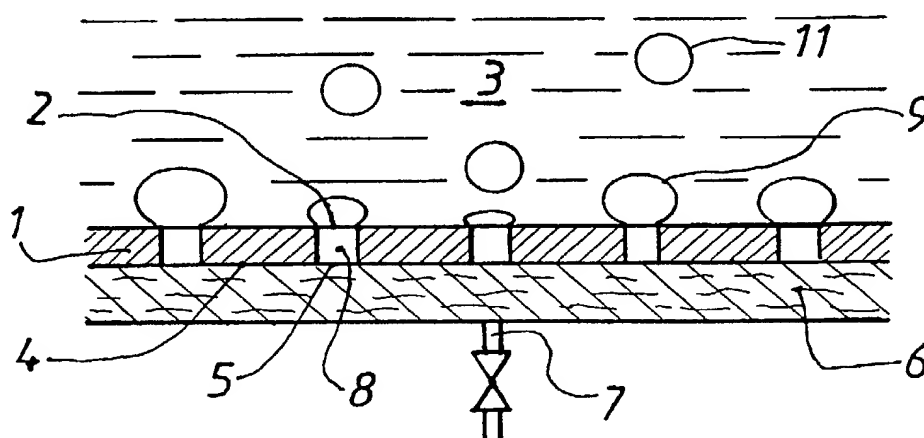
Avec rapport de recherche internationale.

(54) Title: IMPROVED METHOD AND DEVICE FOR DEGASING AND SEPARATION OF INCLUSIONS IN A LIQUID METAL BATH BY INJECTION OF GAS BUBBLES

(54) Titre: PROCEDE ET DISPOSITIF AMELIORES DE DEGAZAGE ET DE SEPARATION DES INCLUSIONS D'UN BAIN DE METAL LIQUIDE PAR INJECTION DE BULLES DE GAZ

(57) Abstract

A device for injecting gas bubbles into a liquid metal (3, 23) contained in a treatment volume, preferably a treatment vessel, a circulation chute for liquid metal or an oven. The inventive device comprises at least one static inert-material injection part (1, 21) provided with a plurality of orifices (2, 22) and the material and/or lay-out of said orifices are such that the ratio between the diameter of the contact surface between each emitted bubble and the material at the exit of the orifice (2, 22) on the diameter of said orifice, or the expansion ratio, is less than 5, preferably 3 or more advantageously 1.5 at the time when the bubble is detached from the material.



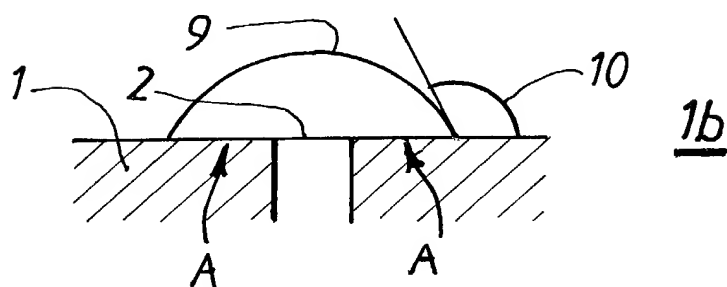
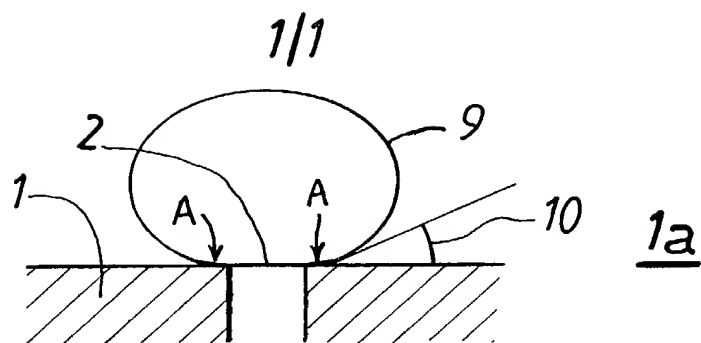


FIG. 1

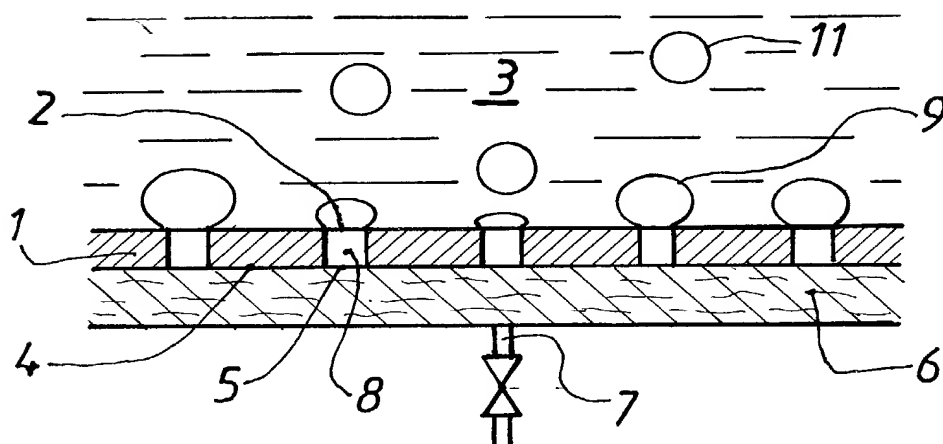


FIG. 2

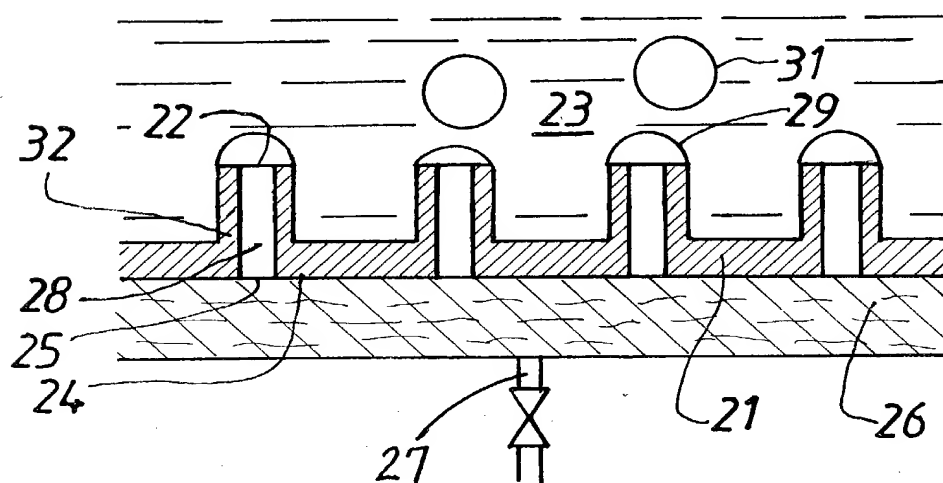


FIG. 3

Docket 01184

DECLARATION (37 CFR 1.63) FOR A UTILITY OR DESIGN
APPLICATION USING AN APPLICATION DATA SHEET

As below named inventor(s), I/we declare that:

This declaration is directed to:

- ☐ The attached application; or
☒ Application No. 09/926,289, filed on October 9, 2001,
☒ as amended on October 9, 2001 (if applicable);

I/we believe that I/we am/are the original and first inventor(s) of the subject matter which is claimed and for which a patent is sought;

I/we have reviewed and understand the contents of the above-identified application, including the claims, as amended by any amendment specifically referred to above;

I/we acknowledge the duty to disclose to the United States Patent and Trademark Office all information known to me/us to be material to patentability as defined in 37 CFR 1.56, including material information which became available between the filing date of the prior application and the National or PCT International filing date of the continuation-in-part application, if applicable; and

All statements made herein of my/our own knowledge are true, all statements made herein on information and belief are believed to be true, and further, that these statements were made with the knowledge that willful false statements and the like are punishable by fine or imprisonment, or both, under 18 U.S.C. 1001, and may jeopardize the validity of the application or any patent issuing thereon.

FULL NAME OF INVENTOR(S)

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☐ Additional inventor(s) is/are being named on additional form(s) attached hereto.